

P27195.A01

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Toshiharu FURUKAWA

Group Art Unit: 1756

Serial No: 10/711,758

Examiner: Unassigned

Filed: October 4, 2004

For: **REDUCED MASK COUNT GATE CONDUCTOR DEFINITION**

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
U.S. Patent and Trademark Office
Customer Service Window, Mail Stop Amendment
Randolph Building
401 Dulany Street
Alexandria VA 22314

Sir :

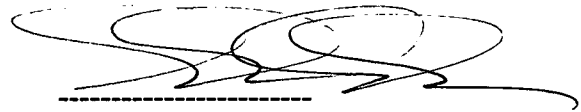
Under the provisions of 37 CFR § 1.97 through § 1.99 and pursuant to applicant's duty of disclosure under 37 CFR § 1.56, applicant respectfully brings the following documents, listed on the attached form PTO-1449, to the attention of the Examiner in charge of the above-identified application. A copy of the cited documents is enclosed for the convenience of the Examiner.

This citation does not constitute an admission that the references are relevant or material to the claims. They are only cited as constituting related art of which the applicant is aware.

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It is respectfully requested that the listed references be considered by the Examiner and formally made of record in this application.

Respectfully submitted,
Toshiharu FURUKAWA

A handwritten signature in black ink, appearing to read 'Andrew M. Calderon', written over a horizontal dashed line.

Andrew M. Calderon
Reg. No.:38,093

March 31, 2005
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U.S. Department of Commerce
Patent and Trademark Office

Atty. Docket No.
P27195

Application No.
10/711,758

**INFORMATION DISCLOSURE STATEMENT
BY APPLICANT**
(Use several sheets if necessary)

Applicant
Toshiharu FURUKAWA

Filing Date
October 4, 2004

Group
1756

U.S. PATENT DOCUMENTS

[illegible]

FOREIGN PATENT DOCUMENTS

[illegible]

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

/M.D./		1	M.L. Kerbaugh, et al. "A Method of Sidewall Image Transfer Utilizing the Polyimide-Nitride Material Interaction", Research Disclosure, February 1988, Number 286.
/M.D./		2	Anonymous, "Process and Mask Structure for Submicrometer-wide Polysilicon or Polycide Emitters", February 1987. Research Disclosure Database Number: 274061, Research Disclosure Journal Number: 27461
/M.D./		3	J.E. Cronin, "Method for Making a Single Sidewall Structure", IBM Technical Disclosure Bulletin, Vol. 30, No. 12, May 1988, pp. 157-158.

EXAMINER /Mahmoud Dahimene/

DATE CONSIDERED 01/31/2008

*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.